

<u>Patent</u>

IN THE UNITED STATES PAT	ENT AND TRADEMARK OFFICE	
In Re Application of:)	
Chau, Robert S et al)	
U.S. Serial No: 10/749,196) Examiner: Blum, David S	
Filed: December 30, 2003) Art Unit: 2813	
For: Replacement Gate Flow Facilitating) g)	
High Yield and Incorporation of Etch)	
Stop Layers and/or Stressed Films		
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450		
Alexanuna, VA 22010-1400		
AMENDMENT AND RESPONSE		
Dear Sir:		

This is in response to the Office Action mailed June 27, 2005. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

FIRST CLASS CERTIFICATE OF MA	AILING
I hereby certify that this correspondence is being deposited with the U with sufficient postage in an envelope addressed to MAIL STOPCOMMISSIONER FOR PATENTS, P.O. Box 1450, Alexandria, VA 22 U.S. Patent and Trademark Office, Washington, D.C. 20231 on Octo	 313-1450
Teresa Mattox	Duic of Deposit
Name of Person Mailing Correspondence	October 20, 2005

Serial Number: 749,196 Docket Number: 42P17294

Signature

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Date